## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: S. KADLEC, et al.

Serial No: 10/798,331

Filed: March 12, 2004

Title: METHOD FOR MANUFACTURING SPUTTER-COATED

SUBSTRATES, MAGNETRON SOURCE AND SPUTTERING

CHAMBER WITH SUCH SOURCE

Group: 1753

Examiner: Michael A. Band

Conf. No.: 6134

## **LETTER**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

January 4, 2008

Sir:

This Letter is responsive to the Interview Summary mailed in the above-identified application on December 12, 2007 and summarizing the results of the December 6, 2007 telephone interview granted by Examiner Michael Band and applicants undersigned attorney. The stated summary of the interview is correct. A more detailed statement of the substance of interview as required by M.P.E.P. §713.04 is set forth in the remarks in the Amendment filed in the application on December 6, 2007.

Respectfully submitted,

/Ronald J. Shore/

Ronald J. Shore

Registration No. 28,577

ANTONELLI, TERRY, STOUT & KRAUS, LLP

RJS/kmh